Excessively High Vapor Pressure of Al-Based Amorphous Alloys

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Abstract: Aluminum-based amorphous alloys exhibited an abnormally high vapor pressure at their approximate glass transition temperatures. The vapor pressure was confirmed by the formation of Al nanocrystallites from condensation, which was attributed to weight loss of the amorphous alloys. The amount of weight loss varied with the amorphous alloy compositions and was inversely proportional to their glass-forming ability. The vapor pressure of the amorphous alloys around 573 K was close to the vapor pressure of crystalline Al near its melting temperature, 873 K. Our results strongly suggest the possibility of fabricating nanocrystallites or thin films by evaporation at low temperatures.

Keywords: amorphous alloy; metallic glass; vapor pressure; glass forming ability

1. Introduction

Sublimation is the phase transition from solid to gas, without passing through an intermediate liquid phase. The equilibrium vapor pressure for sublimation is reached when the vaporization rate is consistent with its condensation rate. Vapor pressure due to sublimation is a function of temperature, and it can be easily estimated using the Clausius-Clapeyron equation [1]. The vapor pressure of metal
alloys resulting from sublimation at one-third or one-half of the melting temperature are typically negligible compared with the vapor pressure of their liquid phase above the melting temperature [2]. Hence, we expect that metal alloys, which exhibit liquid behavior well below their melting temperatures, may show a vapor pressure as high as the vapor pressure of evaporation, near or above their melting temperature.

Many amorphous alloys exhibit liquid-like behavior at temperatures substantially below their melting temperatures. This temperature range is called the supercooled liquid region (SCLR), which ranges from the glass transition temperature ($T_g$) to the crystallization temperature ($T_x$). The liquid-like behavior (reduction in viscosity) of the amorphous alloys in SCLR leads to thermoplastic deformation. For example, some amorphous alloys can be blow-molded into various shapes due to their thermoplastic formability in SCLR [3,4]. In addition, we previously exploited the liquid-like behavior of Al-based amorphous alloys in SCLR to develop Ag paste for solar cells [5–7]. The Ag paste with Al$_{85}$Y$_{10}$Ni$_{5}$Co$_{2}$ (AYNC) exhibited better electrical properties than those with Al$_{85.4}$Y$_{10}$Ni$_{5.5}$ (AYN) and Al$_{86}$Y$_{6}$Ni$_{4.5}$Co$_{2}$La$_{1.5}$ (AYNCL). This is likely because AYNC has higher thermoplastic formability [8], so AYNC is more deformed in SCLR by capillary forces in the paste, which enhanced the electrical properties of the Ag electrodes. There could be other reasons for the better electrical properties of the Ag paste with AYNC, and further investigation is needed.

The vaporization of Al-based amorphous alloys over a temperature range that includes SCLR was confirmed by observing both the weight loss of the amorphous alloys and the formation of Al nanocrystallites from condensation during heating. The Al nanocrystallites formed on a substrate near the amorphous alloys after heating at 573 K. The vapor pressure of the Al-based amorphous alloys over the temperature range from 433 to 593 K measured in this report was approximately $(0.6–1.4) \times 10^{-8}$ Pa, which is similar to the vapor pressure of pure crystalline Al at 853–873 K.

Vapor pressure measurements of a supercooled liquid have been previously reported [9]. For materials in solid phase, the vapor pressure was estimated by measuring and extrapolating the vapor pressure from a supercooled liquid phase immediately below the melting temperature. However, measurements of the vapor pressures of amorphous alloys in SCLR well below the melting temperatures have not been reported.

2. Experimental Section

Al-based amorphous alloy ribbons of three different compositions, AYN, AYNC, and AYNCL, were fabricated. The master alloys of the three compositions were prepared by arc-melting the high purity elements (>99.9% from RND Korea, Gwangmyeong, Korea). Using the master alloys, amorphous ribbons of the three compositions were produced by melt-spinning under Ar gas in a vacuum chamber (base pressure of $10^{-5}$ torr). The thermal property and crystallinity of the amorphous ribbons were confirmed using differential scanning calorimetry (DSC, Perkin-Elmer DSC8000, PerkinElmer, Akron, OH, USA) and X-ray diffraction (XRD, Bruker D8 ADVANCE, Bruker, Billerica, MA, USA). Energy dispersive X-ray spectroscopy (EDX) connected to a scanning electron microscope (SEM, FEI Helios 600i, FEI company, Hillsboro, OR, USA) was used to analyze the Al nanocrystallites formed by condensation, following vaporization of the ribbon. To capture the vapor from the amorphous ribbons, a carbon-coated grid, generally used to prepare samples for transmission electron microscopy (TEM),
was used. The grid was placed on top of an amorphous Al ribbon, which was then transferred into a furnace and heated at 573 K for 15 min in air. The weight loss of the samples per unit area was obtained using thermogravimetric analysis (TGA, TA instrument Q500, TA instruments, New Castle, DE, USA) at a constant heating rate (20 K/min) in air. Additionally, TGA was used to measure the weight loss of the three samples, and Al foil (99.45%, 25 μm thick, from Alfa Aesar, Ward Hill, MA, USA) was used to calculate the enthalpy of vaporization, using an isothermal method at various temperatures under an N₂ atmosphere. Pieces of amorphous ribbon and Al foil that were a few millimeters long were stacked on the TGA cells; their weights before heating were approximately 4 mg. Images of the ribbons (or Al foils) on the TGA cell were obtained, and the area of the top surface of the ribbons exposed to air was measured using Photoshop (Adobe CS6, Adobe system, San Jose, CA, USA). The weight change of the ribbons measured by TGA was divided by the area measured using Photoshop because we assumed that the weight loss of the ribbons was due to the vaporization of Al from the top surface exposed to air. The aluminum that vaporized from one ribbon piece underneath another ribbon immediately condensed on the surface of the ribbons above it.

Figure 1. Weight change per unit area of the three ribbons (Al₈₅.₄Y₁₀Ni₅.₅ (AYN), Al₈₅Y₈Ni₅Co₂ (AYNC), and Al₈₆Y₆Ni₄.₅Co₂La₁.₅ (AYNCL)) measured by (a) TGA and (b) DSC analysis of the three ribbons.

3. Results and Discussion

Vaporization of the Al-based amorphous alloys was confirmed based on the weight loss measured by TGA. The maximum weight loss was \((0.3–1.3) \times 10^{-3} \text{ kg/m}^2\), as shown in Figure 1a, and it was dependent on the amorphous alloy composition. The weight loss started at approximately 373 K and continued up to 673 K, regardless of the composition of the amorphous alloy. This temperature range overlaps with the SCLR of the Al-based amorphous alloys measured in DSC (Figure 1b and Table 1). The AYN ribbon lost more weight than the other ribbons (i.e., Al was more likely to escape from the AYN ribbon than from the other ribbons), possibly because amorphous AYN has a larger free volume than the other ribbons. The compositions with more elements were expected to have less free volume in a solute-solvent system, such as AYN, AYNC, and AYNCL [10,11]. In this system, each solute (e.g., Ni, Y, Co, La) is surrounded by solvent atoms of Al, forming a cluster [12]. The size of the cluster is determined by the bond distances between Al and the solute, as well as by the coordination numbers (CNs) of the solutes; thus, the sizes of the clusters for Ni, Y, Co, and La are different. The mixture of clusters of various sizes leads to a higher packing density, or less free volume. In a cluster, the bond
distances between Al and the solute atoms and the CN of the solutes were extensively investigated [12,13]. Amorphous alloys with less free volume generally exhibited higher glass-forming ability (GFA) [14], and the GFAs of AYN, AYNC, and AYNCL are 0.12, 0.90, and 1.0 mm, respectively [15,16]. Thus, the amount of weight loss varied with the composition of the amorphous alloys, and was inversely proportional to their GFAs.

<p>| Table 1. | $T_g$ and $T_x$ of the ribbons with three compositions, Al$<em>{85.4}$Y$</em>{10}$Ni$<em>{5.5}$ (AYN), Al$</em>{85}$Y$<em>{8}$Ni$</em>{5}$Co$<em>{2}$ (AYNC), and Al$</em>{86}$Y$<em>{6}$Ni$</em>{4.5}$Co$<em>{2}$La$</em>{1.5}$ (AYNCL), measured using DSC profiles provided in Figure 1b. |</p>
<table>
<thead>
<tr>
<th>Composition</th>
<th>$T_g$ (K)</th>
<th>$T_x$ (K)</th>
</tr>
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<tbody>
<tr>
<td>AYN</td>
<td>531</td>
<td>555</td>
</tr>
<tr>
<td>AYNC</td>
<td>530</td>
<td>556</td>
</tr>
<tr>
<td>AYNCL</td>
<td>516</td>
<td>530</td>
</tr>
</tbody>
</table>

The weight gain following the weight loss as the temperature increased above 673 K was due to oxidation after the crystallization of the amorphous alloys [17,18]. The weight change of amorphous alloys while heating is commonly measured to analyze physical properties such as oxidation resistance or magnetic properties. Weight gain of amorphous alloys is generally analyzed when the mechanism of oxidation is investigated. Additionally, the weight loss of amorphous alloys while annealing has been reported, but it was only observed in magnetic alloys [19]. The weight loss of magnetic alloys was due to the magnetic transition as the temperature increased.

![Figure 2. (a) Al oxide nanocrystallites formed on a TEM grid placed on top of an amorphous alloy ribbon during annealing at 573 K for 15 min; (b) EDX analysis results confirming the nanocrystallites are oxidized Al. The signals of Cu and C originated from the carbon-coated Cu grid used as a substrate.](image)

The excessive vaporization of the Al amorphous alloys at low temperatures was substantiated by the formation of Al nanocrystallites from condensation. As shown in Figure 2, many Al particles in the nanometer range formed on the TEM carbon-coated grid placed on top of the AYN ribbon during annealing at 573 K for 15 min in air. The nanocrystallites were composed of Al oxide, according to the results of EDX analysis. It was expected that vaporized pure Al was oxidized during annealing in air. The vaporization of the solute elements was expected, yet they were not detected by EDX.
The formation of nanocrystallites from thermal vaporization was one of the fundamental processes for the fabrication of nanocrystallites or thin films [20–22]. However, the previous reports focused on evaporation above the melting temperature. Inorganic elements, such as Se and As, were used to synthesize their nanocrystallites from sublimation, but their vapor pressures of sublimation are intrinsically high [23]. The vapor pressures of the individual elements consisting of Al-based amorphous alloys Al, Ni, Y, Co, and La are too low to fabricate their nanocrystallites by sublimation [2].

![Figure 3](image.png)

**Figure 3.** (a) The value of $\alpha$ was obtained by comparing the previously reported vapor pressure of Al (dotted line) to the vapor pressures of the Al foils calculated using Equation (1). For the calculation, the weight loss rates of the Al foils were measured at various temperatures as shown in (b) and the vapor pressures at these temperatures were calculated using Equation (1) with the three possible values of alpha, $1.8 \times 10^4$ (red line), $3.5 \times 10^4$ (blue line), and $7.0 \times 10^4$ (green line). The optimum value of $\alpha$ is approximately $3.5 \times 10^4$.

The vapor pressure of the amorphous alloys was in the range $(0.6–1.4) \times 10^{-8}$ Pa, which is exceptionally higher than that of crystalline Al in the same temperature range. The vapor pressure was comparable to that of crystalline Al over the temperature range from 853 to 873 K. It was reasonable to compare the vapor pressure of the amorphous alloys to that of pure Al because more than 84% of the amorphous alloys were Al. Moreover, the vapor pressures of individual elements consisting of the amorphous alloys are lower than that of Al over the same temperature range. The vapor pressure of the amorphous alloys was calculated using the weight loss rate measured by TGA. Conventional TGA equipment was previously used to estimate the vapor pressure of materials at atmospheric pressure [24,25]. According to previous reports, Equation (1) was proposed to estimate the vapor pressure from the evaporation rate, adapting the Knudsen-Langmuir equation that describes free evaporation in a vacuum, as follows: [26]

$$\frac{dm}{dt} = \alpha S P_v \sqrt{\frac{M_A}{2 \pi R T}}$$

where $\frac{dm}{dt}$ is the evaporation rate, $S$ is the evaporating surface area, $P_v$ is the vapor pressure, $R$ is the gas constant, $T$ is the temperature, $M_A$ is the molecular weight of the evaporating substance, and $\alpha$ is a vaporization constant. The value of $\alpha$ is strongly dependent on the experimental conditions, especially
the purge gas. The value of $\alpha$ for our experimental condition was obtained by measuring $\frac{dm}{dt}$ of pure crystalline Al foil under isothermal conditions at various temperatures in TGA (Figure 3). Because the vapor pressure of crystalline Al is known, the value of $\alpha$ was calculated using Equation (1) and found to be approximately $3.5 \times 10^4$. With the same experimental condition, $\frac{dm}{dt}$ of the amorphous ribbons was measured, and the results are summarized in Figure 4.

$$\ln(P_v) = -\frac{\Delta H_{\text{vap}}}{RT} + C$$

Figure 4. (a) Vapor pressures of AYN, AYNC, and AYNCL as a function of temperature: The data points fit a straight line for each composite and were used to calculate the enthalpy of vaporization; and (b–d) the individual data points of the three composites in (a) were obtained by measuring weight losses per unit area as a function of time at various temperatures in TGA.

The $\Delta H$ for vaporization of the Al-based amorphous alloys close to the value of $T_g$ was estimated using the Clausius-Clapeyron equation (Equation (2)). The data points in Figure 4 fit a straight line for each composition, and the enthalpy of vaporization was estimated from the slope of the straight line. The enthalpy of vaporization for the amorphous alloys was over the range 1.2–12.6 kJ/mol (see Table 2), and the error ranges caused by linear fitting were in the range 3.3–5.4 kJ/mol. Although errors exist, the calculated enthalpies were substantially lower than the $\Delta H$ for the vaporization of pure Al at melting temperature (approximately 284 kJ/mol). The temperature range for the vaporization was approximately from 373 to 673 K, and it overlapped with SCLR, regardless of the amorphous alloy compositions. In SCLR, the enthalpy of the glass transition of amorphous alloys is attributed to the
change in heat capacity. In addition to heat capacity, other endothermic or exothermic reactions in SCLR have also been previously reported [27–31]. The origins of additional reactions in SCLR are the occurrence of phase separation, short-range or medium-range ordering, and an increase in local immiscibility of liquids in SCLR. To the best of our knowledge, the enthalpy of vaporization of amorphous alloys in SCLR is a novel finding.

Table 2. Enthalpy changes of vaporization for ribbons of three compositions.

<table>
<thead>
<tr>
<th>Composition</th>
<th>$\Delta H$ (kJ/mol)</th>
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<tr>
<td>AYN</td>
<td>12.6 ± 5.4</td>
</tr>
<tr>
<td>AYNC</td>
<td>5.9 ± 3.6</td>
</tr>
<tr>
<td>AYNCL</td>
<td>1.2 ± 3.3</td>
</tr>
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</table>

4. Conclusions

In conclusion, we revealed that the vapor pressure of Al-based amorphous alloys well below their melting temperatures was comparable to that of crystalline Al near its melting temperature, 873 K. In the temperature range 453–593 K, the vapor pressure of the AYN, AYNC, and AYNCL alloys measured in this study was $(0.6–1.4) \times 10^{-8}$ Pa. The vapor pressure was comparable to that of pure Al over the temperature range 853–873 K. An unexpectedly high amount of vaporization at this low temperature was substantiated by the weight loss determined by TGA and the formation of Al nanocrystallites from condensation after heating. The amount of weight loss varied with the composition of the Al-based amorphous alloys, and it was inversely proportional to GFA.

Acknowledgments

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Author Contributions

S.J.K. wrote and edited the paper, and contributed in all activities. J.I.J. performed DSC and TGA experiment and analyzed the results. S.H.L. synthesized amorphous ribbons using arc-melting and melt-spinning. J.J. performed XRD and SEM experiment and analyzed the results.

Conflicts of Interest

The authors declare no conflict of interest.

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